

# Some theories (& history) of sputtered ion formation

Peter Williams

Arizona State University

“when primary Canalstrahlen strike against a plate of metal, secondary rays are produced. These . . . are for the most part uncharged, but a small fraction carry a positive charge”

**J.J. Thomson, Phil. Mag. 20 (1910) 752.**

## A New Process of Negative Ion Formation

By F. L. ARNOT, Ph.D., Lecturer in Natural Philosophy, and J. C.  
MILLIGAN, M.A., B.Sc., The University, St. Andrews

*(Communicated by H. S. Allen, F.R.S.—Received 27 March, 1936)*



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## The formation of negative ions by positive-ion impact on surfaces

BY R. H. SLOANE, D.Sc. AND R. PRESS, M.Sc.

*Queen's University, Belfast*

*(Communicated by E. V. Appleton, F.R.S.—Received 12 July 1938)*

Formation of hydrocarbon cluster ions in poor vacuum

## On the Yield and Energy Distribution of Secondary Positive Ions from Metal Surfaces\*

HENRY E. STANTON  
*Argonne National Laboratory, Lemont, Illinois*

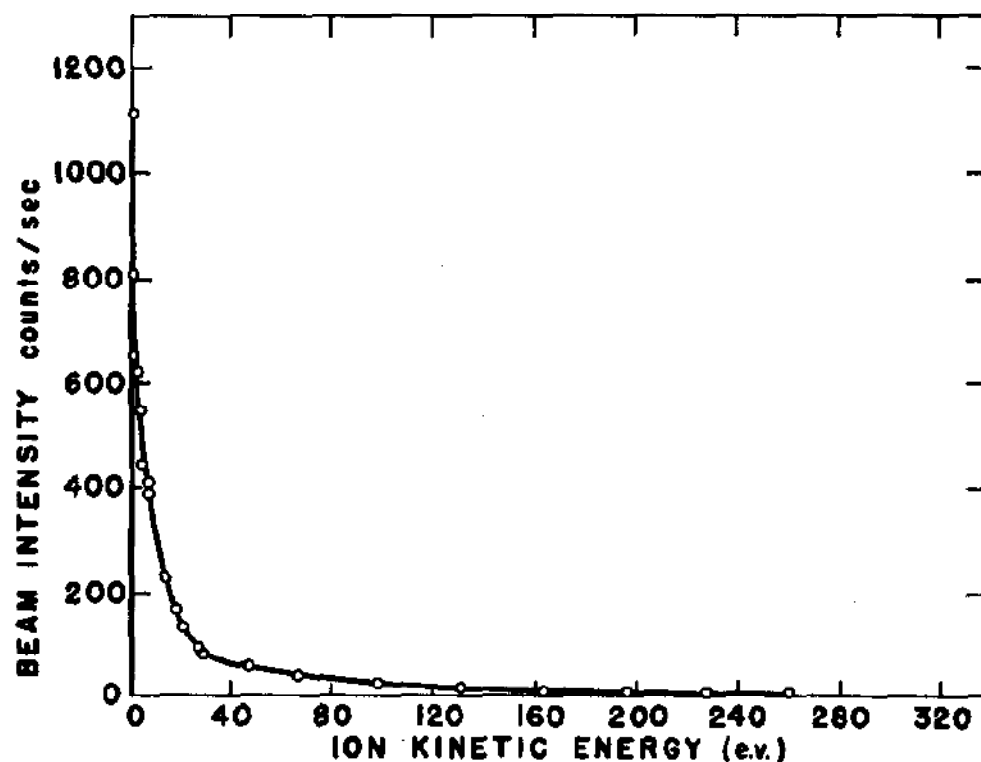


FIG. 8. The distribution of kinetic energy of  $\text{Be}^+$  ions driven from the target under bombardment by neon ions of 1000-e.v. energy.

-- not a simple Boltzmann thermal distribution

Arifov Institute (Tashkent, Uzbekistan)

Morov & Ayukhanov, Radio Engineering & Electron Physics **8** 280 (1963)

-- observed that ion yields from ionic substances, e.g. NaCl could be very high, e.g. ~ 30% for Cl<sup>-</sup> from NaCl

Title: SUR L'EMISSION ELECTRONIQUE SECONDAIRE DES METAUX BOMBARDES PAR DES IONS POSITIFS

Author(s): SLODZIAN G

Source: COMPTES RENDUS HEBDOMADAIRES DES SEANCES DE L'ACADEMIE DES SCIENCES 246 (26): 3631-3634 **1958**

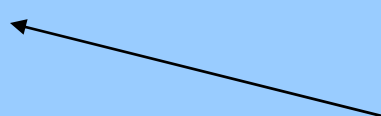
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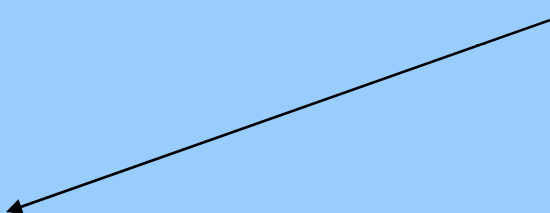
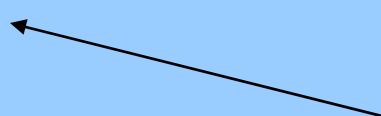
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*First ion microscope; observed ion yield enhancement by oxygen*

Arifov Institute (Tashkent, Uzbekistan)

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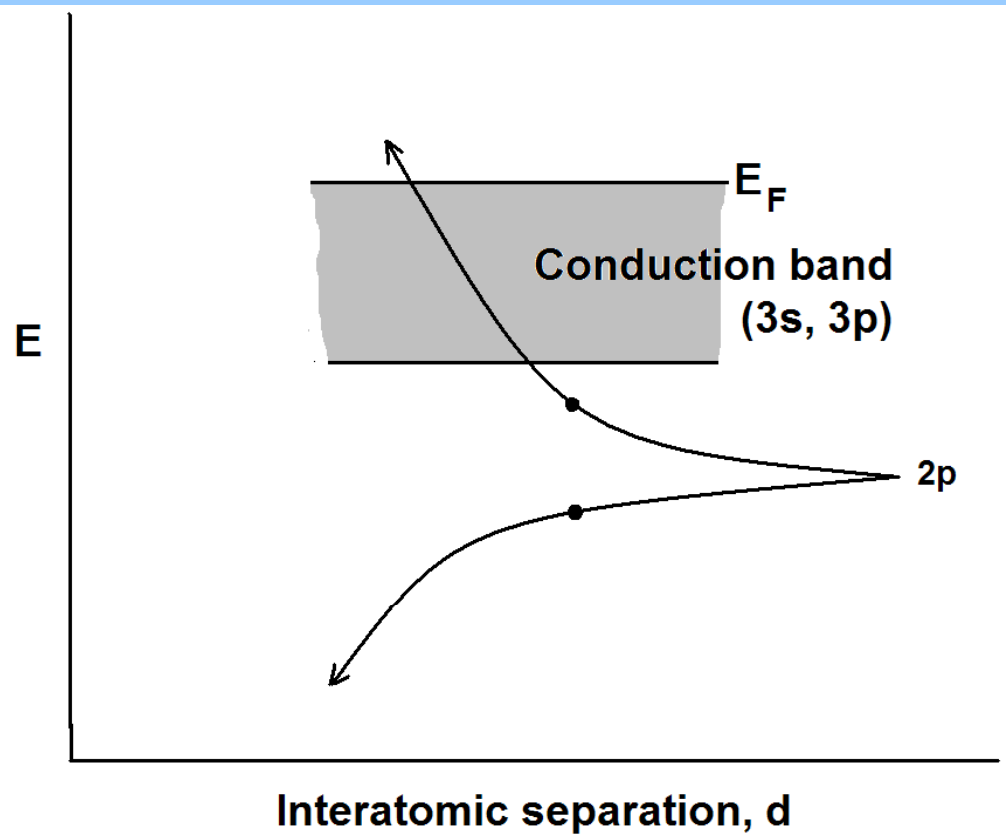
## “Intrinsic” ion emission from “clean” metal surfaces

Issues:

- how are ions created in (at) the surface?
- how do ions escape from the surface un-neutralized?

Joyes (1968-70): Auger de-excitation model

Collisional electron promotion model of Joyes for Mg, Al, Si (P. Joyes, 1968-70):



- An electron in an antibonding state derived from the 2p orbital can be promoted to an energy above the Fermi level, and detach, leaving an excited atom with a 2p hole
- IF the 2p hole lifetime is long enough ( $\sim 10$  fs for Mg, Al, Si) the atom can move  $> 5$  Å from the surface before Auger de-excitation ejects 1 or 2 e's, giving 1+ or 2+ ions that cannot then be neutralized by electron tunneling

## Evidence for electron-promotion model:

- observation of multiply-charged ions of Mg, Al, Si at relatively low energies
- observation of ion-induced Auger electrons
- works even for 4<sup>th</sup>-period elements (initially thought to have too short core-hole lifetimes)

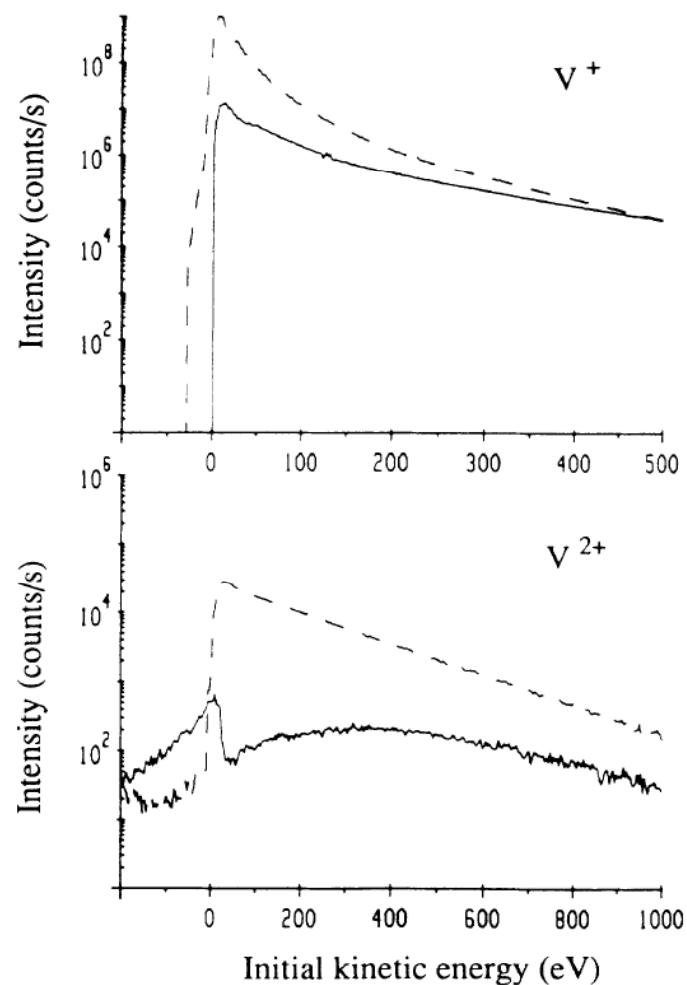
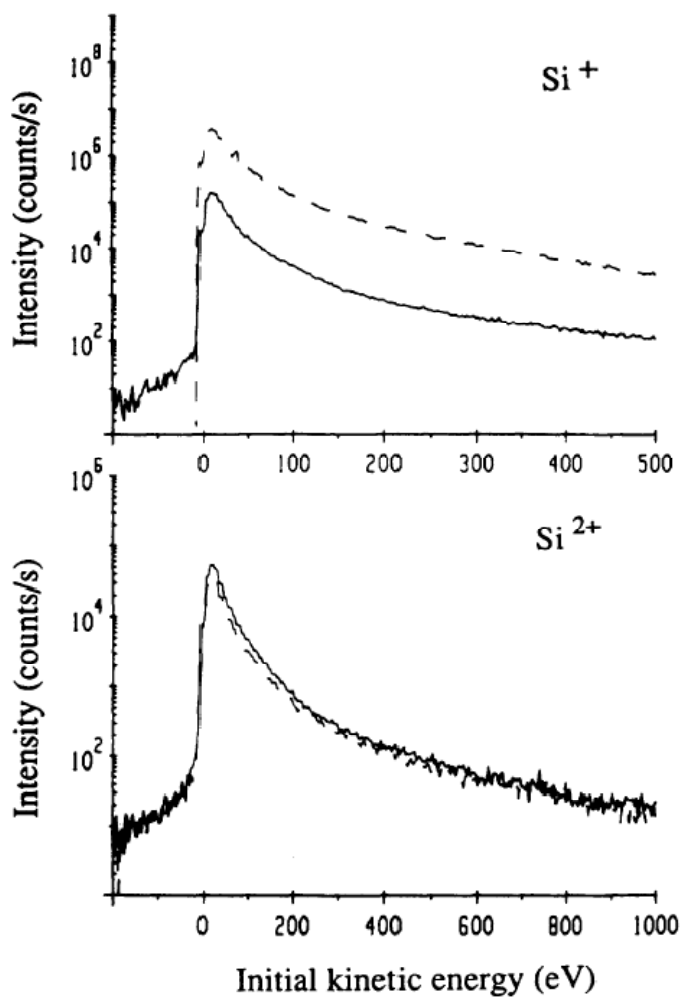
## Doubly charged sputtered ions of fourth-row elements

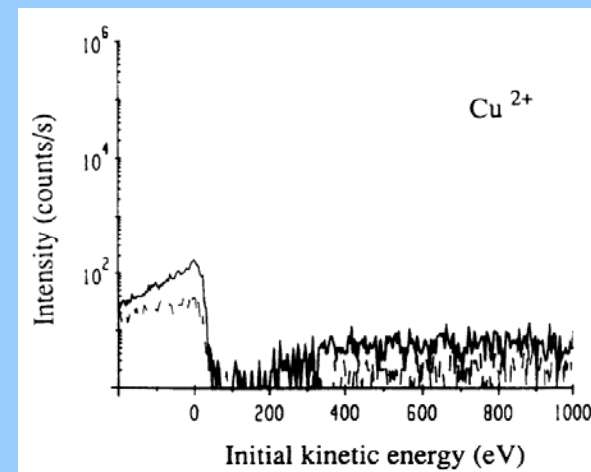
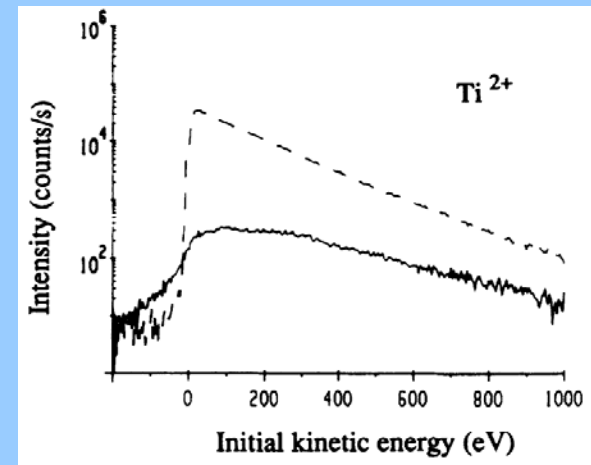
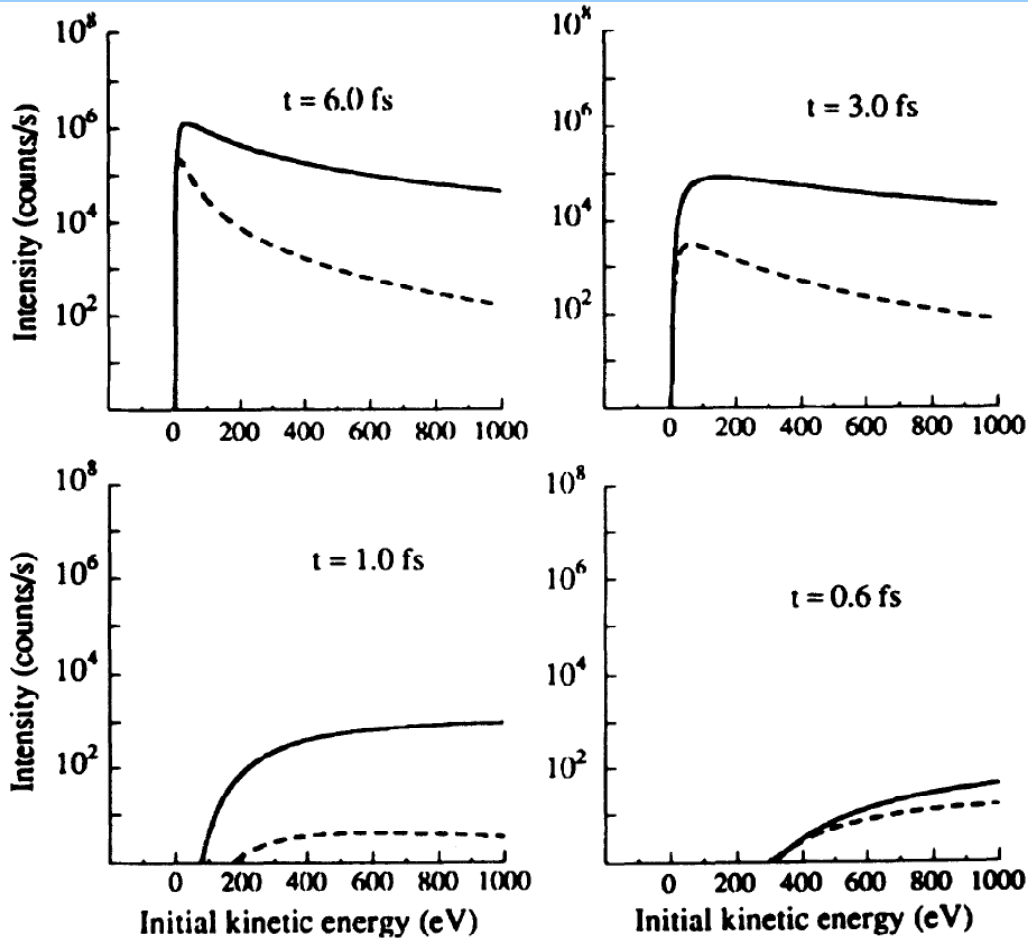
Stephen N. Schauer

*U.S. Army Electronics Technology and Devices Laboratory, SLCET-EP, Fort Monmouth, New Jersey 07703-5601*

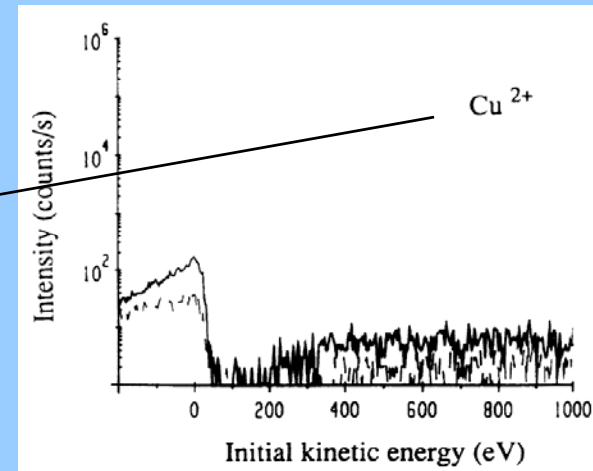
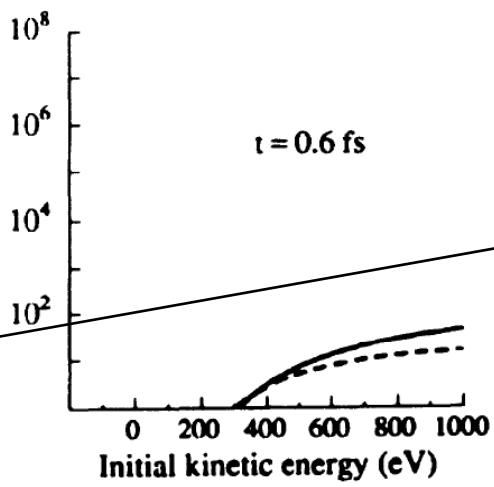
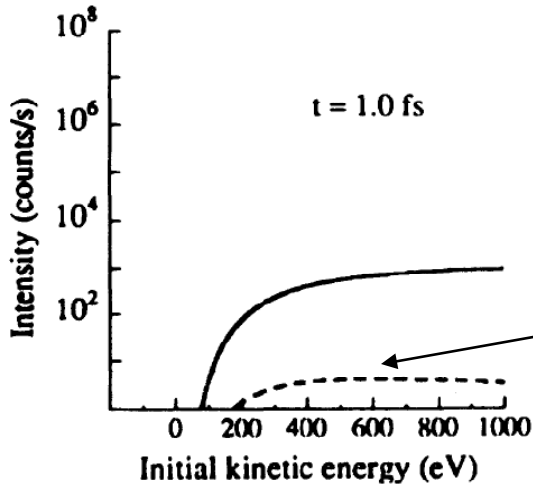
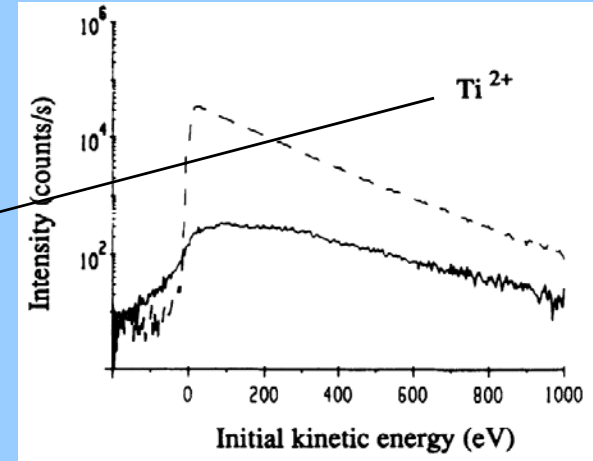
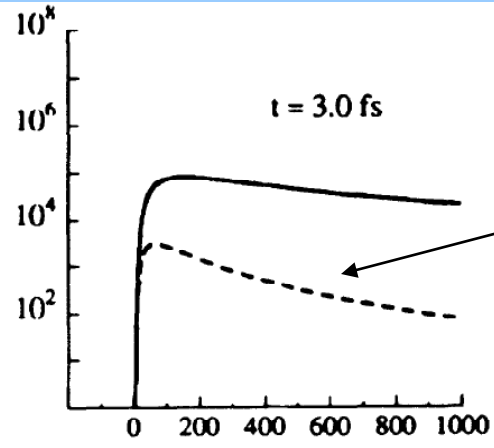
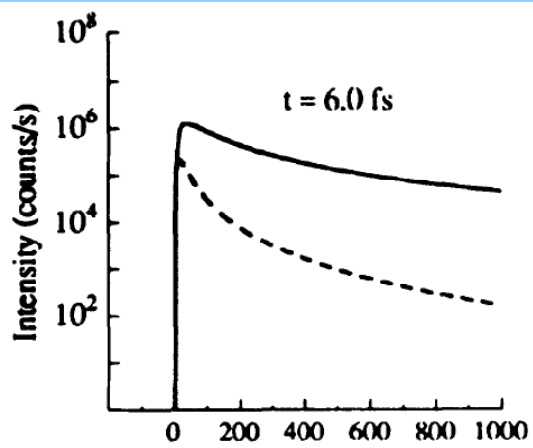
Peter Williams

*Department of Chemistry, Arizona State University, Tempe, Arizona 85287-1604*





Predicted energy distributions for different vacancy lifetimes  
(Solid lines: total E; dotted lines: after transmission through MS)



Predicted energy distributions for different vacancy lifetimes

## “Intrinsic” ion emission from “clean” metal surfaces

### Issues:

-- how are ions created?

-- how do ions escape from the surface un-neutralized?

Perturbation model: Blaise & Slodzian 1970, Nourtier 1976, Blandin, Nourtier & Hone 1976, Norskov & Lundqvist 1979... atoms are excited (ionized) by the perturbation associated with rapid detachment from the surface; then survive neutralization (by electron transfer from the surface) to escape as ions

## “Intrinsic” ion emission from “clean” metal surfaces

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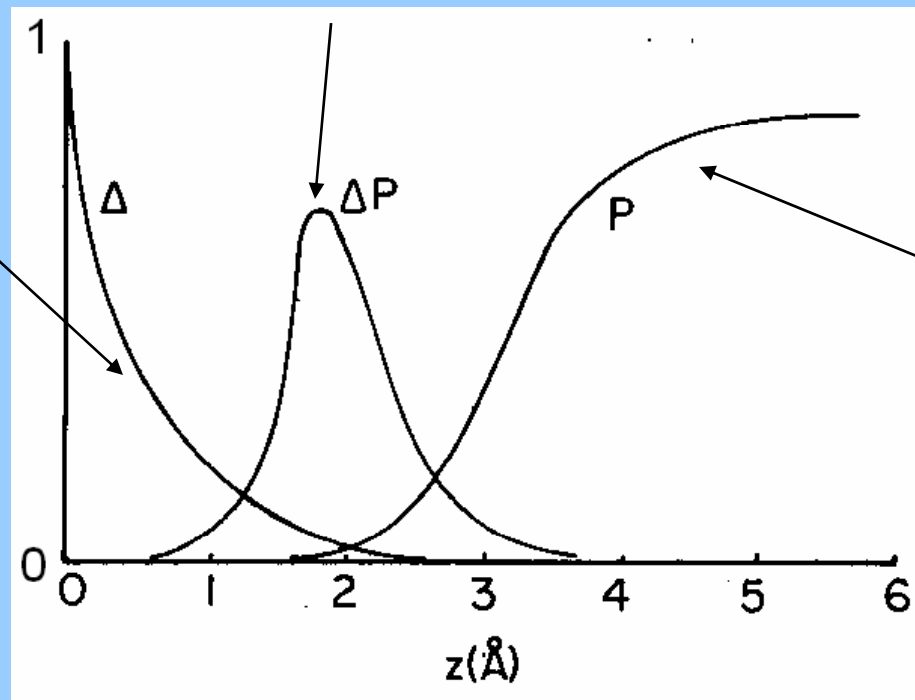
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*Excitation probability*

*Ionization probability ( $\times 10^n$ )*



*Escape probability*

## Issues with the perturbation model:

- a) How to accurately characterize the “surface” during the sputtering event?  
-- see MD simulations
- b) Is there really an “average” sputtering event?
- c) Is there really a “kinetic” emission process on “clean” surfaces?  
  
-- i.e. Ion yields ( $\sim 10^{-4} - 10^{-6}$ ) are comparable to the level of oxygen contamination in the bulk or from the vacuum  
  
-- is all ionization associated with oxygen?

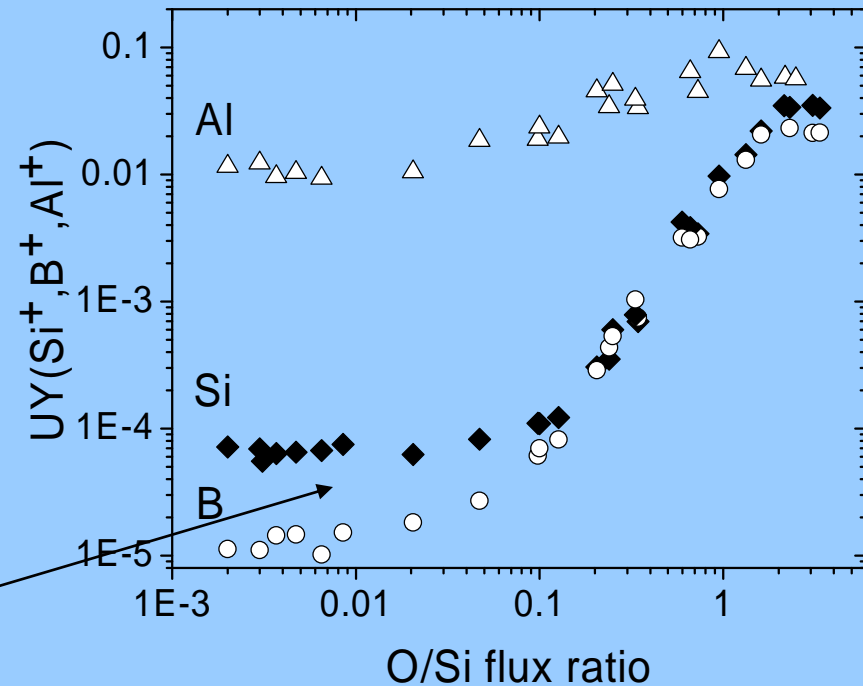
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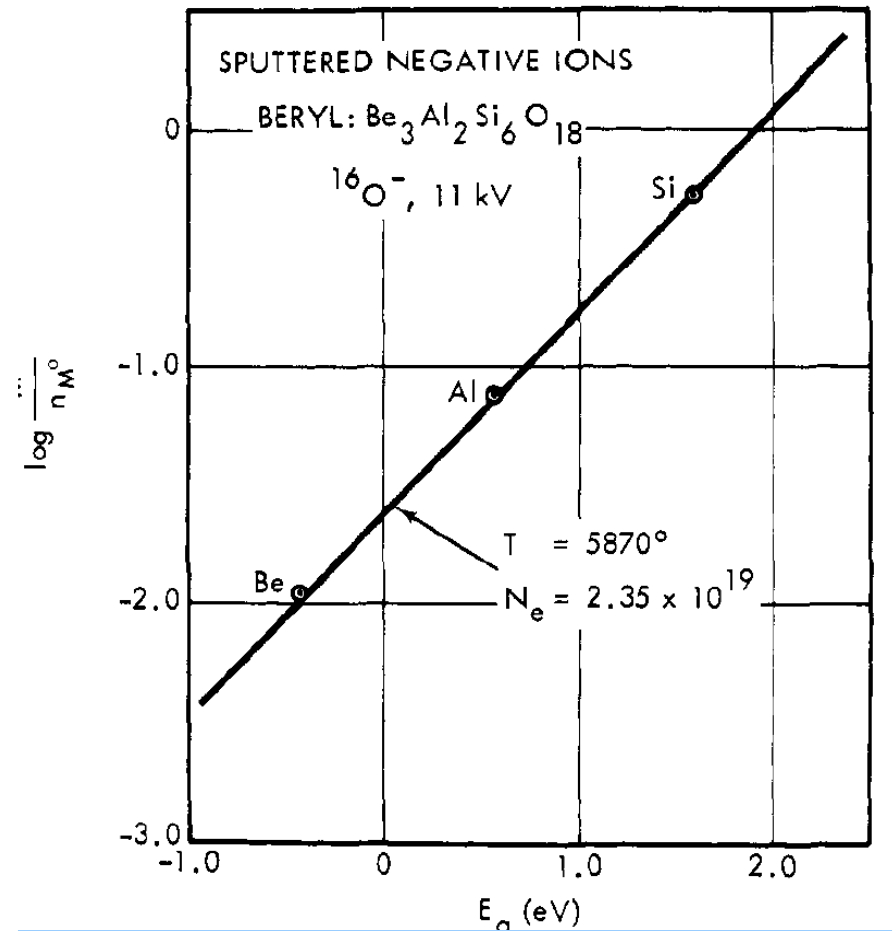
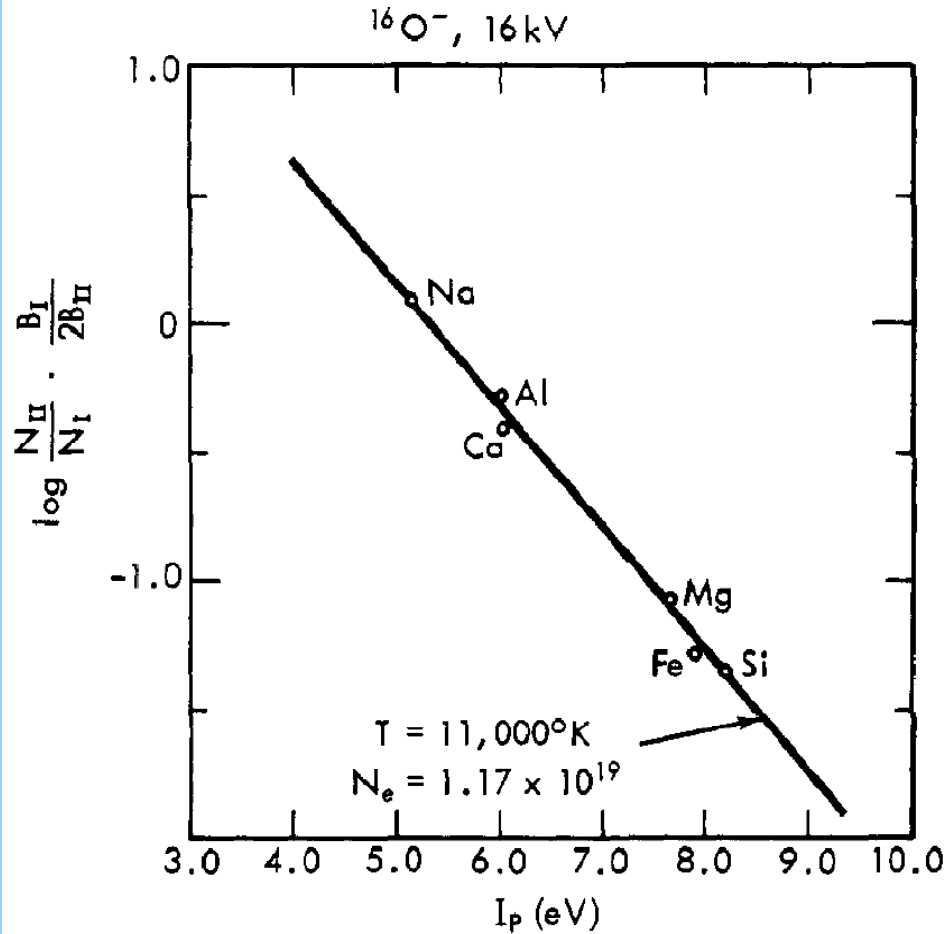
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-- is all ionization associated with oxygen?

NO – kinetic emission does occur



C.A. Andersen & J.R. Hinthorne 1973: "CARISMA"



Saha-Eggert:  
("plasma eqn.)

$$K_{n^+} = \frac{n_{M^+} n_{e^-}}{n_{M^0}} = \left( \frac{2\pi m_{M^+} m_{e^-}}{h^2 m_{M^0}} kT \right)^{3/2} \frac{B_{M^+} B_{e^-}}{B_{M^0}} e^{-E/kT}$$

# C.A. Andersen & J.R. Hinthorne 1973: "CARISMA"

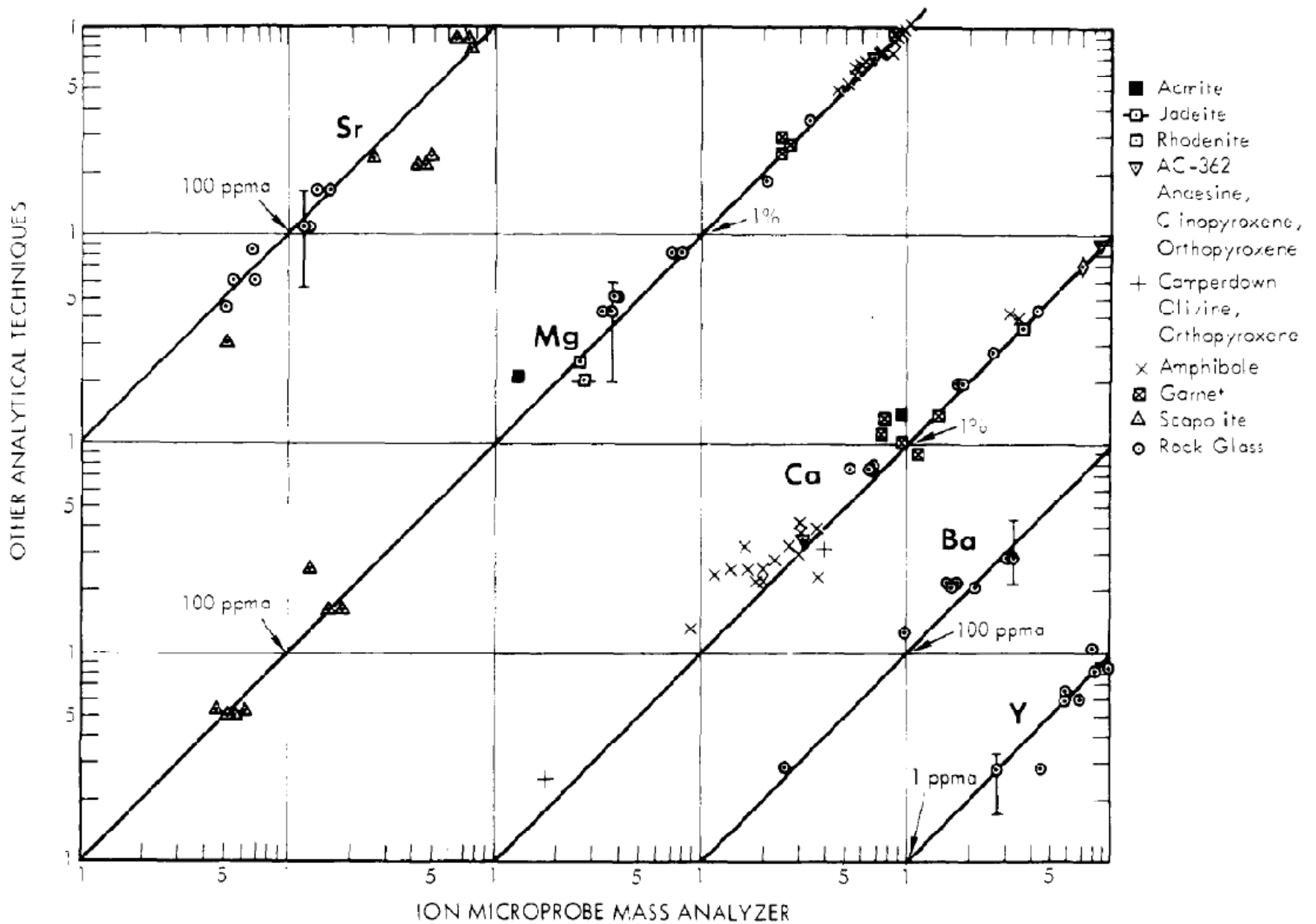


Figure 6. Comparison of the analyses of the ion microprobe mass analyzer with those of other analytical techniques for the alkaline earth elements plus yttrium in silicate matrices

“CARISMA” was infuriating because it was

(a) proprietary – hard to check. Used extensive compilations of partition functions and a proprietary computer program

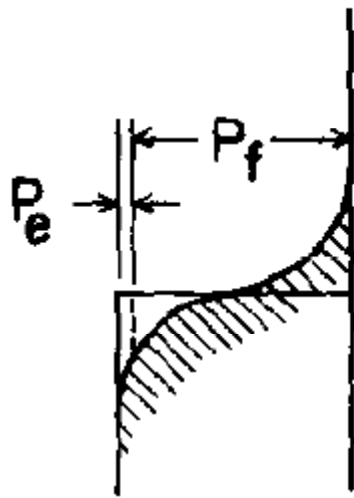
(b) physically unreal – i.e. there is NO physical evidence for a plasma in thermodynamic equilibrium at the sputtering site

(c) it worked

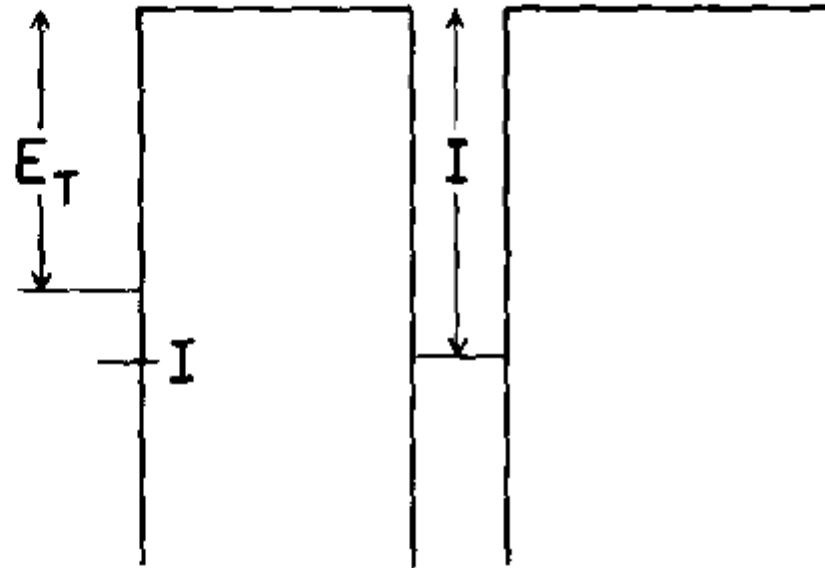
1974: Drew Evans asked Dave Simons to look into this: Dave produced a much simpler approach that worked equally well

-- showed that a Saha-Langmuir equation fit the data equally well if  $\phi$  and T are allowed to be fitting parameters

$$\frac{n^+}{n_0} = \frac{A^+}{A_0} \exp \frac{-(I - \phi)}{kT}$$



**Electron Energy  
Distribution**



**Surface**

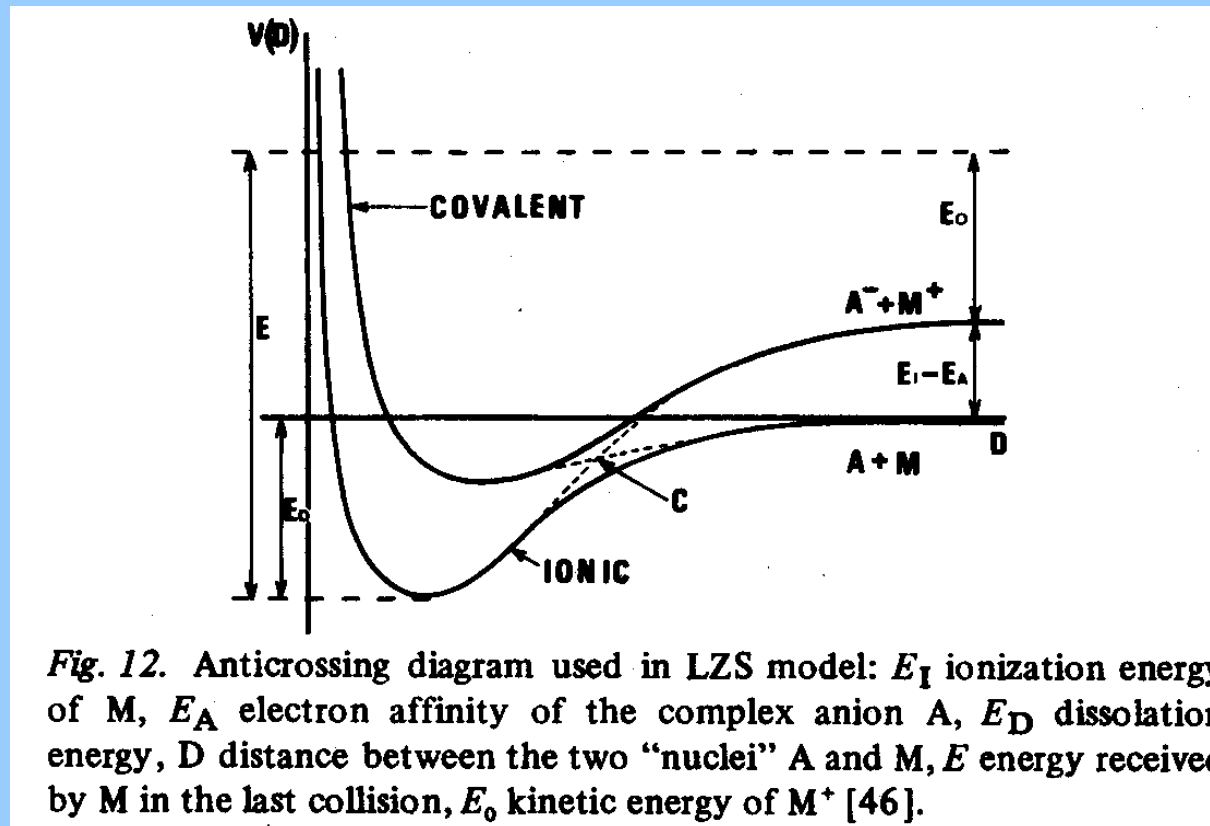
**Atom**

**Potential Energy Diagram**

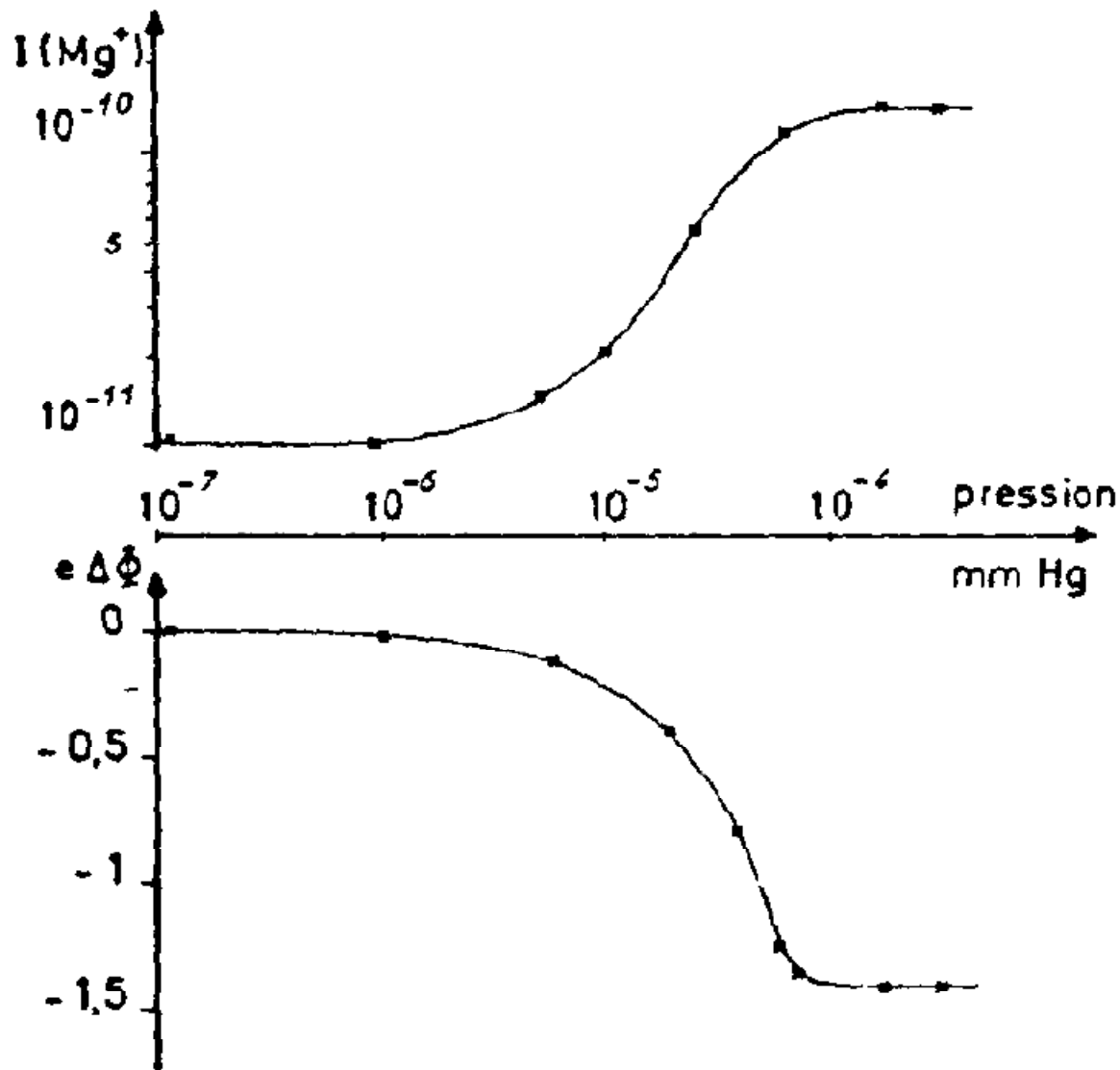
“Surface excitation” model (PW 1979): assume collisionally excited electrons equilibrate to a Fermi-Dirac distribution on a time scale faster than the ion departs  
 -- then a Saha-Langmuir equation for ionization follows

Slodzian: metal positive ion yields enhanced by oxygen

-- "bond-breaking model" -- rupture of ionic M-O bonds yields  $M^+$ ,  $O^-$



From Slodzian, Physica Scripta 1982



“work function” is not a good parameter to explain positive ion effects of oxygen

G. Blaise and G. Slodzian. Surface Sci. 40 (1973) 708.  
 EFFETS COMPARÉS DE L'OXYGÈNE SUR L'ÉMISSION  
 IONIQUE ET LE POTENTIEL DE SURFACE DES MÉTAUX

### Primary oxygen ion implantation effects on depth profiles by secondary ion emission mass spectrometry

R. K. Lewis

*Cameca Instruments, Incorporated, Elmsford, New York 10523*

J. M. Morabito

*Bell Telephone Laboratories, Allentown, Pennsylvania 18100*

J. C. C. Tsai

*Bell Telephone Laboratories, Reading, Pennsylvania 19600*  
(Received 23 May 1973)

**Appl. Phys. Lett., Vol. 23, No. 5, 1 September 1973**

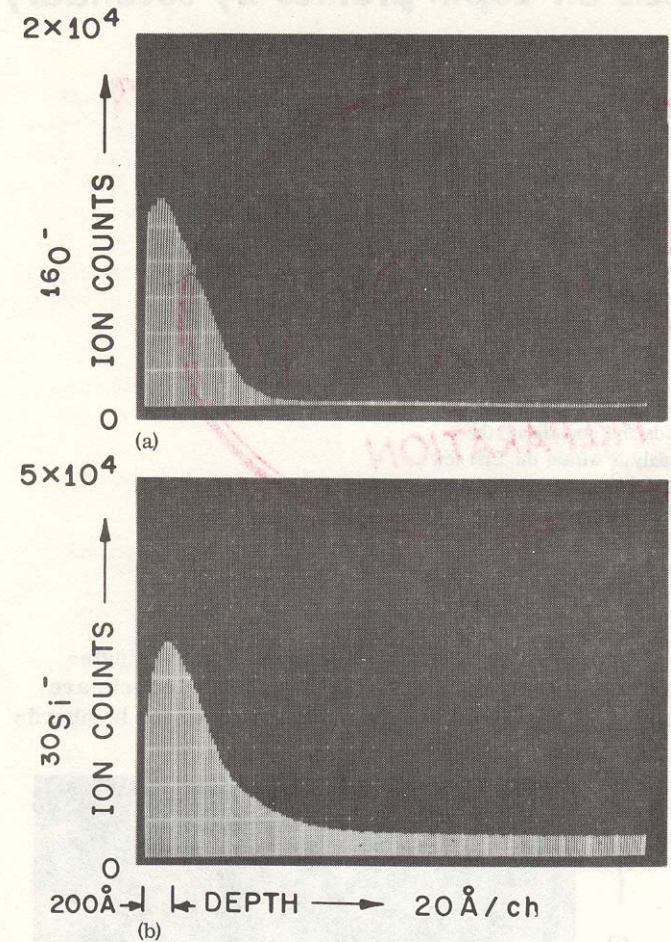
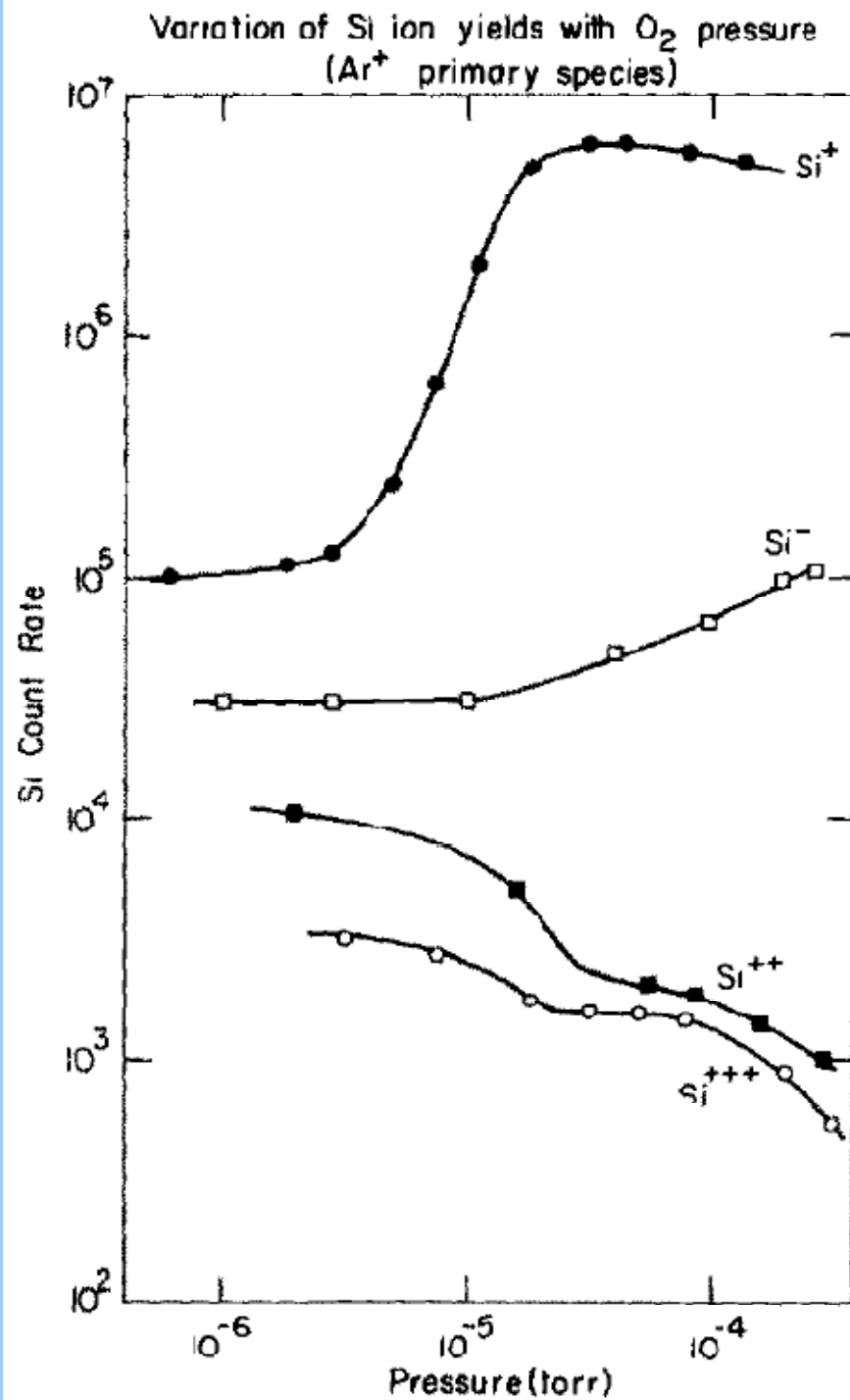
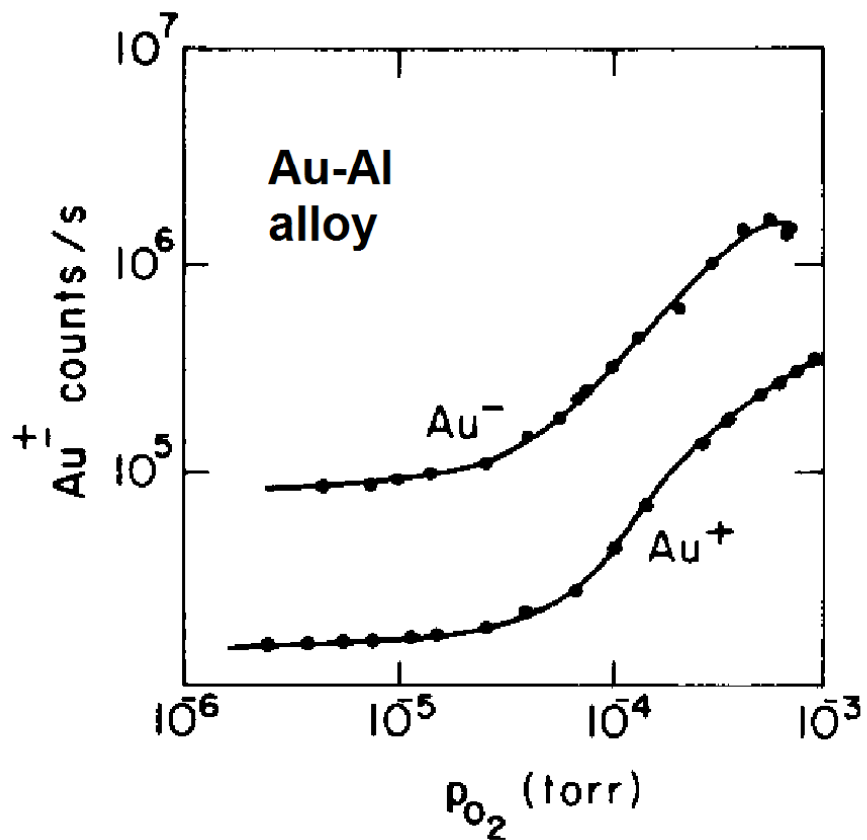
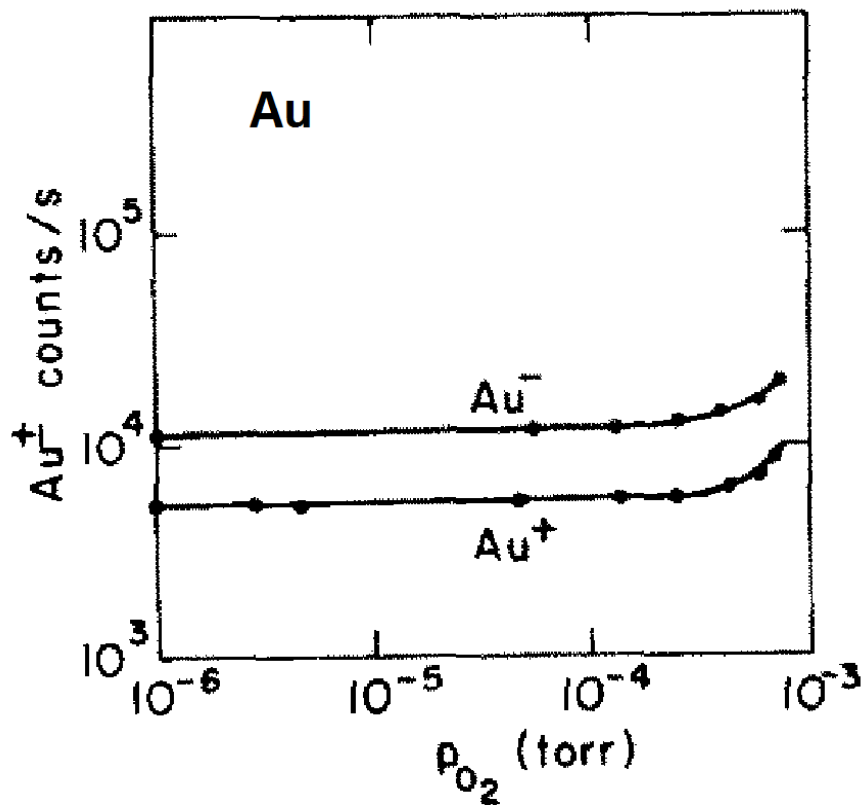


FIG. 2. Comparison of (a) oxygen and (b) silicon signals in a previously measured crater in sample A. Primary ion,  $\text{Ar}^+$  at 14.5 keV. Sputtering rate,  $100 \text{ \AA}/\text{sec}$ .

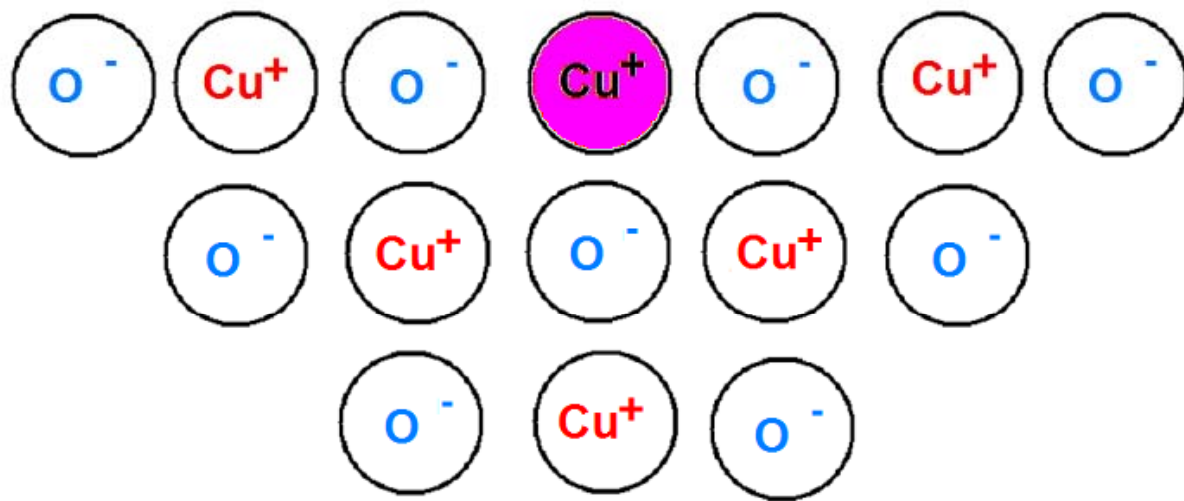


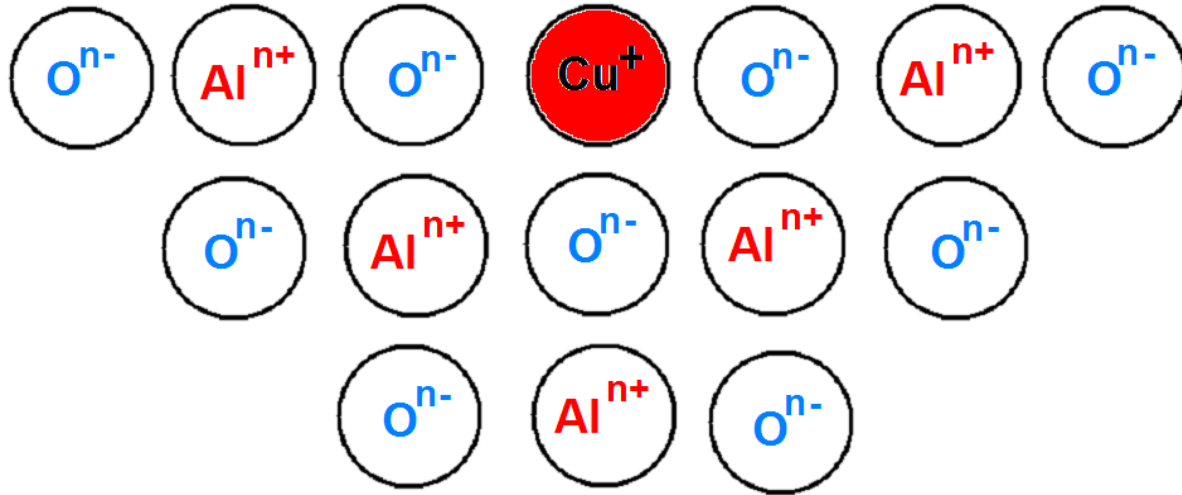
### ANOMALOUS ENHANCEMENT OF NEGATIVE SPUTTERED ION EMISSION BY OXYGEN

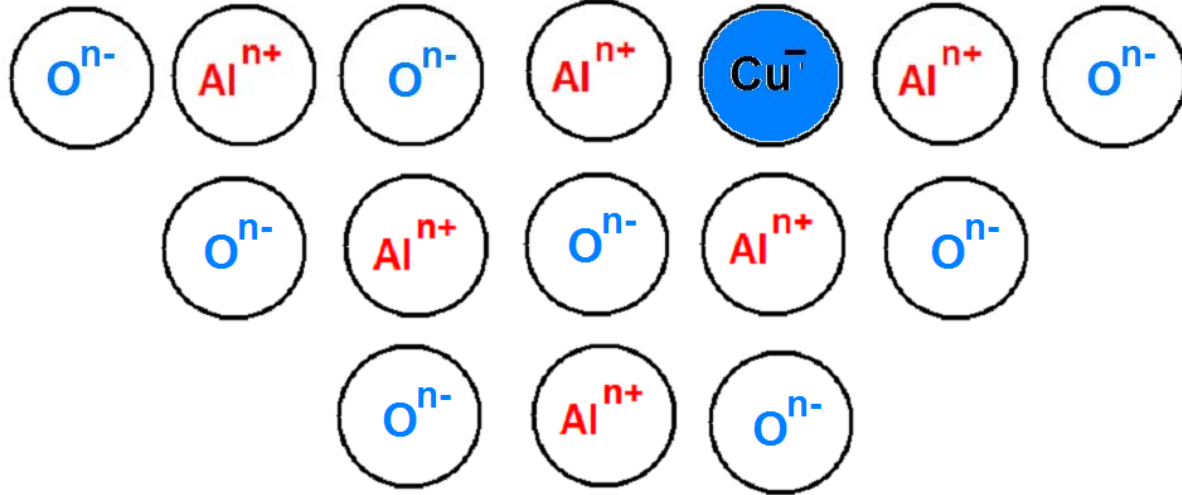
Peter WILLIAMS and Charles A. EVANS, Jr. \*  
Surface Science 78 (1978) 324–338



$O_2$ -induced enhancement of  $Au^-$ ,  $Au^+$  yields in pure Au and Au-Al alloy







## Summary:

-- Sputtered ion formation is COMPLICATED

-- how do we define/describe a surface?

-- how do we treat complex many-body collisions in the sputtering site?

-- do thermal models have ANY validity?

-- maybe an electron “temperature” is a valid concept

-- need clean experiments